

LINEAR SYSTEMS

Twenty-Five Years Of Quality Through Innovation

FEATURES

LOW NOISE	$e_n = 8 \text{nV}/\text{Hz}$ TYP.
LOW LEAKAGE	$I_G = 10 \text{pA}$ TYP.
LOW DRIFT	$ V_{GS1-2}/T = 5 \mu\text{V}/^\circ\text{C}$ max.
LOW OFFSET VOLTAGE	$ V_{GS1-2} = 2 \text{mV}$ TYP.

ABSOLUTE MAXIMUM RATINGS¹

@ 25°C (unless otherwise noted)

Maximum Temperatures

Storage Temperature	-55°C to +150°C
Operating Junction Temperature	-55°C to +150°C

Maximum Voltage and Current for Each Transistor¹

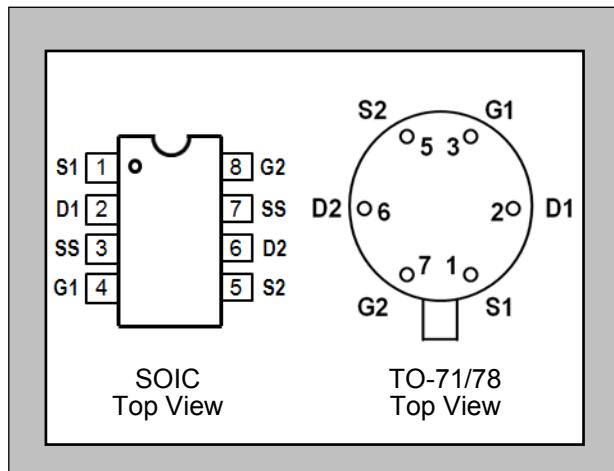
-V _{GSS}	Gate Voltage to Drain or Source	60V
I _{G(f)}	Gate Forward Current	10mA

Maximum Power Dissipation

Device Dissipation ² @ Free Air - Total	400mW	T _A =+25°C
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LS840 LS841 LS842

LOW NOISE LOW DRIFT
LOW CAPACITANCE
MONOLITHIC DUAL N-CHANNEL JFET

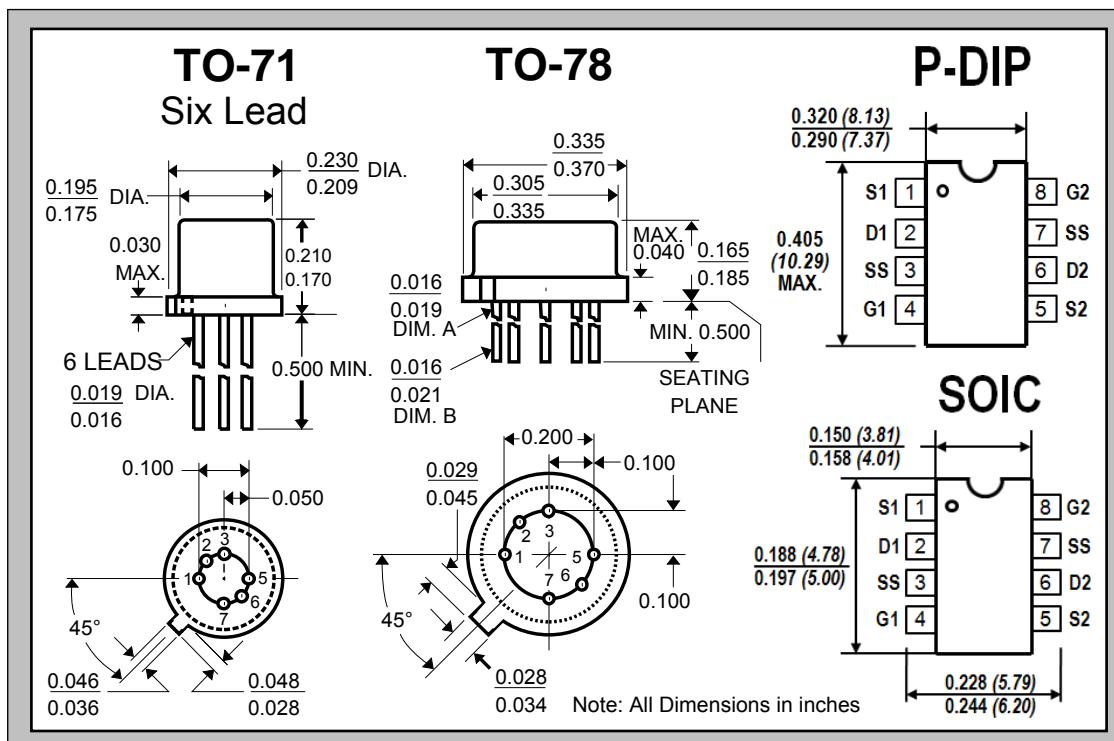


ELECTRICAL CHARACTERISTICS @ 25°C (unless otherwise noted)

SYMBOL	CHARACTERISTIC	LS840	LS841	LS842	UNITS	CONDITIONS
V _{GS1-2} /T max.	Drift vs. Temperature	5	10	40	μV/°C	V _{DG} = 20V I _D = 200μA T _A = -55°C to +125°C
V _{GS1-2} max.	Offset Voltage	5	10	25	mA	V _{DG} = 20V I _D = 200μA

SYMBOL	CHARACTERISTIC ³	MIN.	TYP.	MAX.	UNITS	CONDITIONS
BV _{GSS}	Breakdown Voltage	-60	--	--	V	V _{DS} = 0 I _D = -1nA
BV _{GGO}	Gate-to-Gate Breakdown	±60	--	--	V	I _{GGO} = ±1μA I _D = 0 I _S = 0
<u>TRANSCONDUCTANCE</u>						
G _{fs}	Full Conduction	1000		4000	μS	V _{DG} = 20V V _{GS} = 0 f = 1kHz
G _{fs}	Typical Conduction	500		1000	μS	V _{DG} = 20V I _D = 200μA
G _{fs1} ⁴ G _{fs2}	Mismatch Transconductance Ratio	0.97		1.0		
<u>DRAIN CURRENT</u>						
I _{DSS}	Full Conduction	0.5	2	5	mA	V _{DG} = 20V V _{GS} = 0
I _{DSS1} ⁴ I _{DSS2}	Drain Current Ratio	0.95		1.0		
<u>GATE-SOURCE</u>						
V _{GS(off)}	Pinchoff Voltage	-1	-2	-4.5	V	V _{DS} = 20V I _D = 1nA
V _{GS}	Operating Range	-0.5	--	-4	V	V _{DS} = 20V I _D = 200μA
<u>GATE CURRENT</u>						
-I _G	Operating	--	10	50	pA	V _{DG} = 20V I _D = 200μA
-I _G	High Temperature	--	--	50	nA	V _{DG} = 20V I _D = 200μA T _A = +125°C
-I _G	Reduced VDG	--	5	--	pA	V _{DG} = 10V I _D = 200μA
-I _{GSS}	At Full Conduction	--	--	100	pA	V _{DG} = 20V V _{DS} = 0

SYMBOL	CHARACTERISTIC	MIN.	TYP.	MAX.	UNITS	CONDITIONS
	<u>OUTPUT CONDUCTANCE</u>	--	--	10	μS	
G _{DS}	Full Conduction	--	--	10	μS	V _{DS} = 20V V _{GS} = 0
G _{OS}	Operating	--	0.1	1	μS	V _{DS} = 20V I _D = 200μA
G _{OS} 1-2	Differential	--	0.01	0.1	μS	
	<u>COMMON MODE REJECTION</u>	--	100	--	dB	V _{DS} = 10 to 20V I _D = 200μA
CMRR	-20 log V _{GS1-2} / V _{DS}	--	75	--	dB	V _{DS} = 5 to 10V I _D = 200μA
	<u>NOISE</u>	--	--	0.5	dB	
NF	Figure	--	--	0.5	dB	V _{DS} = 20V V _{GS} = 0 R _G = 10M f= 100Hz NBW= 6Hz
e _n	Voltage	--	--	10	nV/Hz	V _{DS} = 20V I _D = 200μA f= 1KHz NBW= 1Hz
e _n	Voltage	--	--	15	nV/Hz	V _{DS} = 20V I _D = 200μA f= 10Hz NBW= 1Hz
	<u>CAPACITANCE</u>	--	4	10	pF	
C _{ISS}	Input	--	4	10	pF	V _{DS} = 20V I _D = 200μA
C _{RSS}	Reverse Transfer	--	1.2	5	pF	
C _{DD}	Drain-to-Drain	--	0.1	--	pF	V _{DS} = 20V I _D = 200μA



NOTES:

1. These ratings are limiting values above which the serviceability of any semiconductor may be impaired
2. Derate 4mW/°C above 25°C
3. All MIN/TYP/MAX limits are absolute numbers. Negative signs indicate electrical polarity only.
4. Assumes smaller number in the numerator.

Linear Integrated Systems (LIS) is a 25-year-old, third-generation precision semiconductor company providing high-quality discrete components. Expertise brought to LIS is based on processes and products developed at Amelco, Union Carbide, Intersil and Micro Power Systems by company President John H. Hall. Hall, a protégé of Silicon Valley legend Dr. Jean Hoerni, was the director of IC Development at Union Carbide, co-founder and vice president of R&D at Intersil, and founder/president of Micro Power Systems.